

AZ BARLI II Solvent Compatible Bottom Antireflective Coating for i-Line Process

Data Package



AZ BARLi II Coating Material

Features, Process, and Performance

AZ's bottom antireflective coating material, AZ BARLi II coating, is tailor-made to yield near-optimum values for refractive indices (n and k) for i-line lithography, which ensures minimum reflectivity and maximum swing reduction for photoresist layers.

AZ BARLi II coating material is formulated in photoresist-compatible solvents to simplify edge bead removal process and to be both environmentally and user friendly.

Composed of highly absorptive polymer-bound dyes, this material provides excellent coating uniformity and step coverage. Other features include high etch selectivity and good thermal stability.



AZ BARLi II Coating Material

Features/Benefits

- Highly absorptive polymer-bound dye used as the bottom antireflective coating for i-line photoresists
- Near-optimal optical constants (n/k=1.63/0.31) for maximum swing reduction at the optimal film thicknesses (910Å and 1960 Å)
- Formulated with photoresist-compatible solvents to simplify EBR process and to be end-user friendly
- Excellent coating uniformity and step coverage profile
- High etch selectivity, comparable to AZ BARLi coating material
- High thermal stability up to 230°C
- No intermixing with photoresist layer after soft baking
- Two thickness grades, AZ BARLi II 90 and 200, provide the optimal film thickness for the first and the second swing minimum respectively



Optical Constants of AZ BARLi and AZ BARLi II Coatings

Near-optimal values of n and k at 365 nm, both AZ BARLi and AZ BARLi II coatings are highly absorptive materials for i-line process

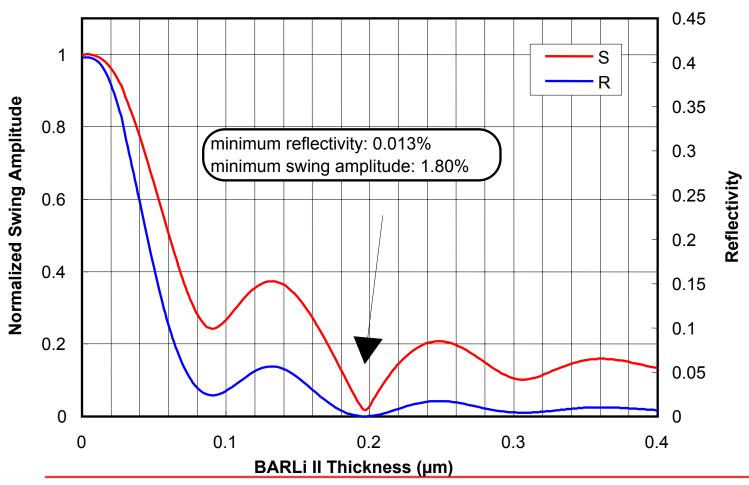
Coating	Wavelength (nm)	n from spectr. ellipsometry	k from spectr. ellipsometry
BARLi	365	1.65	0.33
BARLi II	365	1.63	0.31

BARLi film baked at 150 °C, BARLi II film baked at 200°C



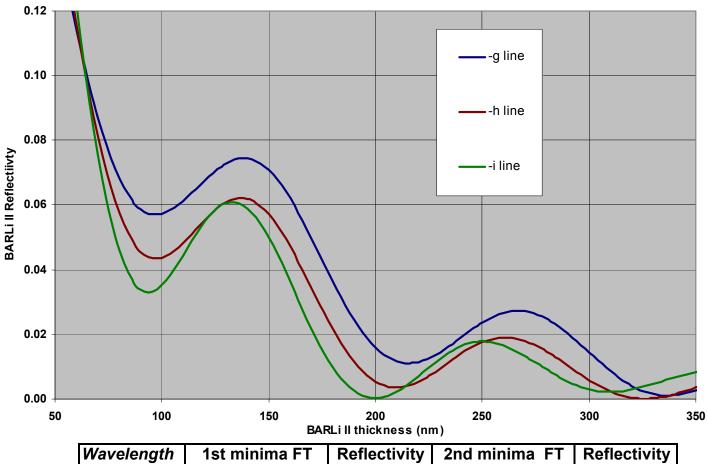
Simulated Swing Reduction of Photoresist by AZ BARLi II Coating

Resist (n=1.704-0.024i) on AZ BARLi II (n=1.63-0.31i) on Si (n=6.55-2.07i), 365nm





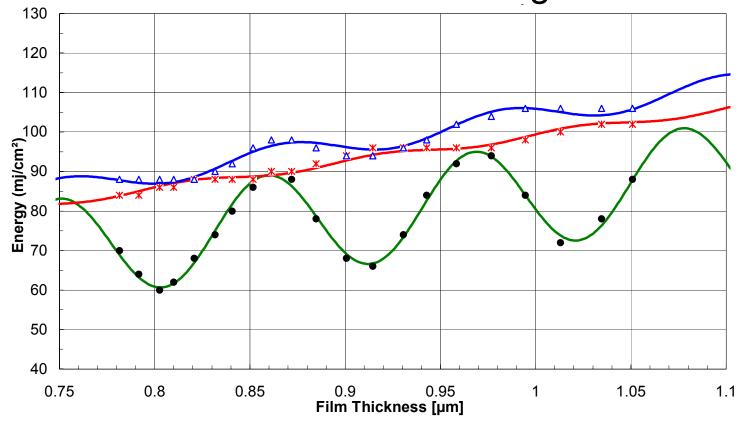
AZ® BARLi II Reflectivity Simulation



Wavelength	1st minima FT	Reflectivity	2nd minima FT	Reflectivity
(λ)	(nm)	(%)	(nm)	(%)
-i line	94	0.0330	200	0.0002
-h line	98	0.0430	212	0.0031
-g line	98	0.0570	216	0.0111



Swing Curves of AZ 7908 Photoresist on AZ BARLi II Coatings



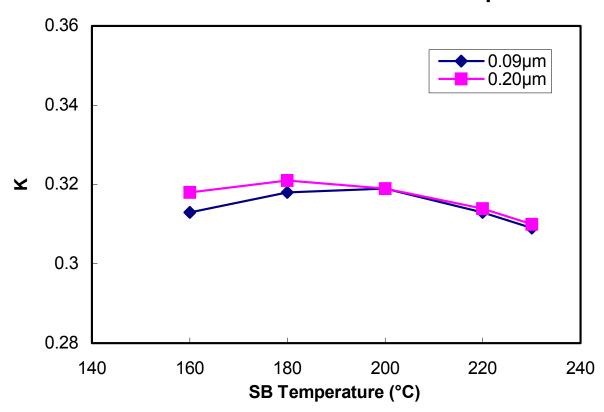
AZ BARLi II at 900Å (blue) and 1960Å (red) SB 90°C/60sec, PEB 110°C/60sec, AZ 300MIF Developer, 70sec puddle @23°C

AZ BARLi II coatings reduced swing amplitude by 80% at 900Å film thickness and 94% at 1960Å



Thermal Stability of AZ BARLi II Coating

Refractive Index K vs. Softbake Temperature

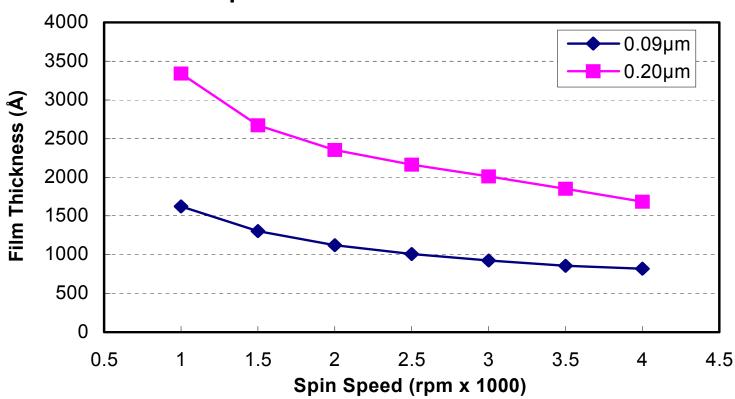


Refractive index k changed < ±2% at softbake temperature from 160°C to 230°C, providing wide process latitude.



Spin Curves of AZ BARLi II Coatings

Spin Curve at 200°C Softbake

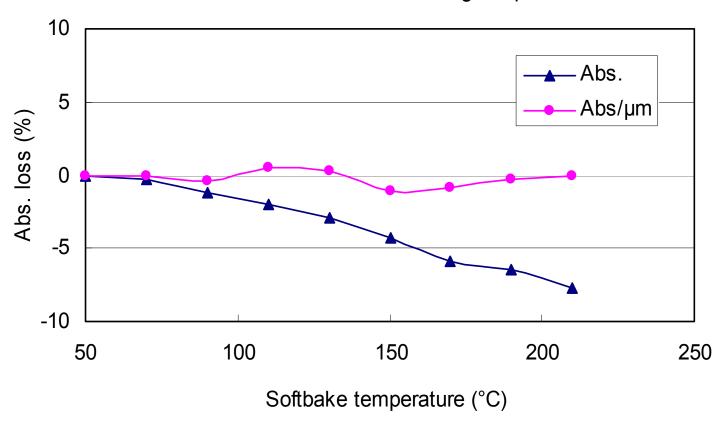


Two thickness grades of AZ BARLi II coatings provide 1st and 2nd optimal FT respectively at standard operating conditions (spin @ 3000rpm,SB @ 200°C/60sec.)



Thermal Stability of AZ BARLi II Coating

Absorbance loss vs. softbaking temperature



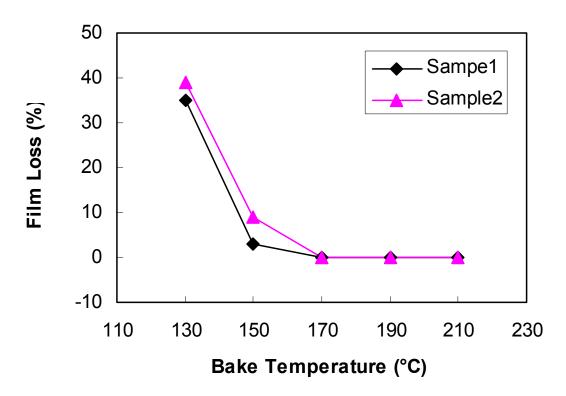
Optical density of AZ BARLi II film varied < ±1.0 % from 50°C to 210°C, indicating high thermal stability.



Thermal Stability of AZ BARLi II Coating

AZ BARLi II Film Loss vs. Soft Baking Temperature

AZ BARLi II films soft baked at 200°C for 60 sec., and then soaked in EL for 60 sec.



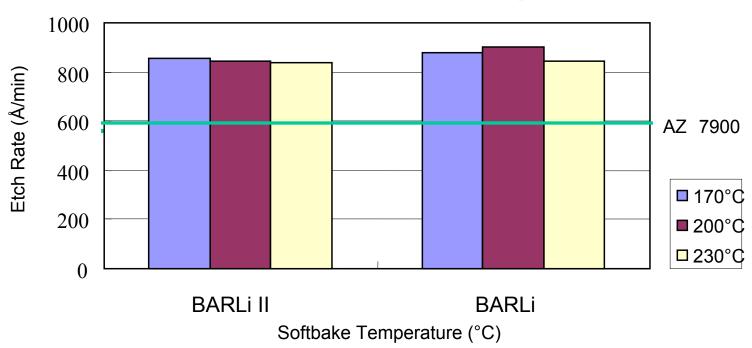
No intermixing with photoresist solvents observed after soft baking at 170°C or higher



Etch Test of AZ BARLi and AZ BARLi II Coatings

Both AZ BARLi and BARLi II coatings are highly etchable

Etch Rate vs. Softbake Temperature

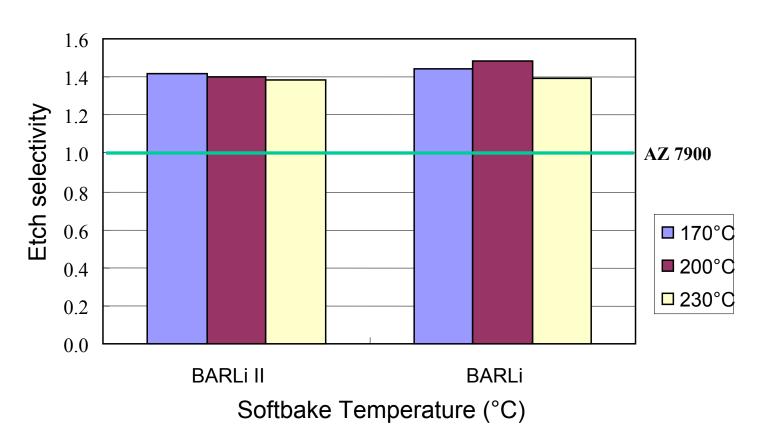


Etch conditions: Samco RIE-10N, CHF₃/O₂ in 40/10 sccm, 60w, 60 seconds.



Etch Selectivity of AZ BARLi and AZ BARLi II Coatings

Both AZ BARLi and AZ BARLi II coatings showed etch selectivity of higher than 1.4 vs. Novolak-based photoresist

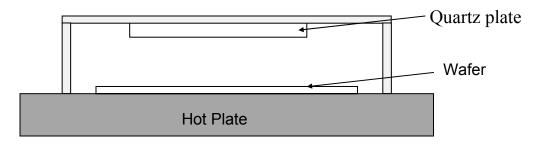


Etch conditions: Samco RIE-10N, CHF₃/O₂ in 40/10 sccm, 60w, 60 seconds.

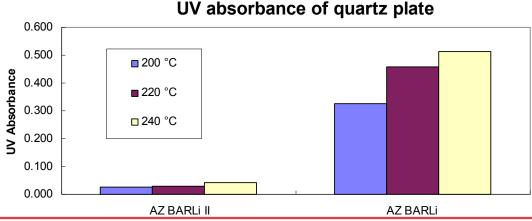


Sublimation Test of AZ BARLi and BARLi II Coatings

AZ BARLi II coating showed high thermal stability and no sublimation of absorptive materials at up to 240°C



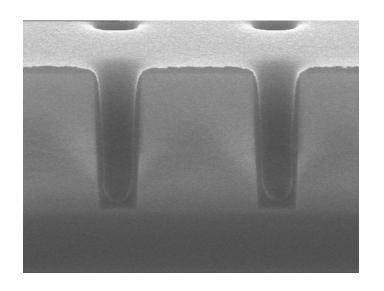
Sublimation test: AZ BARLi II coated @ 0.3 µm onto ten 4" Si-wafers and each baked for 120sec, quartz wafer measured for absorbance after 10 Si-wafers baked.

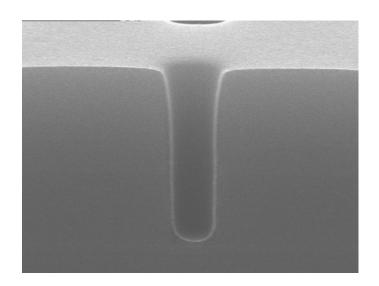




Topography Profiles of AZ BARLi II Coating

AZ BARLi II coating showed good conformity properties

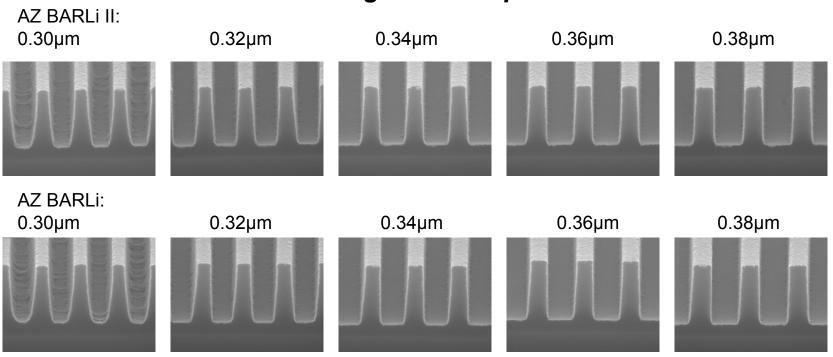




AZ BARLi II material coated onto SiO_2 wafers with contact holes at ~1.7 μ m deep and 0.4 μ m open.

SEM Micrographs of AZ 7908 Resist on AZ BARLi II and AZ BARLi

Resolution better than 0.32µm, showed AZ BARLi II and AZ BARLi coatings are comparable

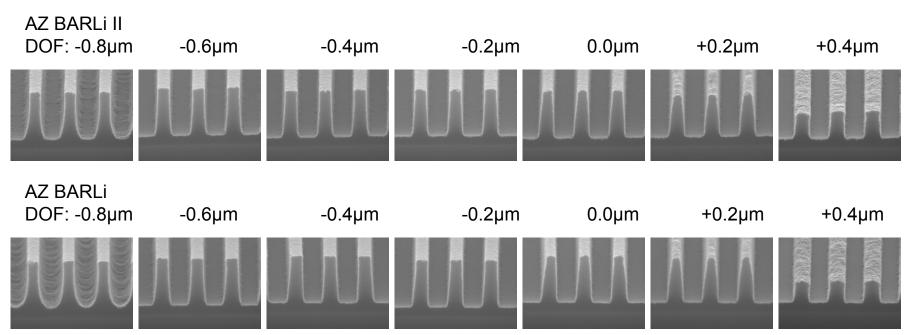


AZ BARLi II &AZ BARLi FT at 0.19µm, SB 200°C/60sec., AZ 7908 FT at 0.97µm, SB 90°C/60sec., PEB 110°C/60sec., Developer AZ 300MIF 23°C/70sec., Exposure Nikon 0.54NA i-line.



SEM Micrographs of AZ 7908 Resist on AZ BARLi II and BARLi

DOF 1.2µm (at 0.34µm), comparable performance for both AZ BARLi II and AZ BARLi coatings.



AZ BARLi II & AZ BARLi FT at 0.19µm, SB 200°C/60sec., AZ 7908 FT at 0.97µm, SB 90°C/60sec., PEB 110°C/60sec., Developer AZ 300MIF 23°C/70sec., Exposure Nikon 0.54NA i-line.



Recommended Standard Process

Substrate Pre-Treatment

HMDS not recommended.

Spin Process

Target thickness: 910Å for AZ BARLi II 90

1960Å for AZ BARLi II 200

Spin and EBR process similar to photoresist process.

Apply static or dynamic dispense at 500-1000rpm.

Final spin speed approx. 3000rpm, actual setting depends on equipment, set spin speed to meet target thickness as above.

EBR Process

AZ EBR70/30 recommended for best result. Also compatible to EL, PGME, or other solvents.



Recommended Standard Process (continued)

Softbake

Recommended setting: 200°C/60seconds on contact hotplate. Depending on equipment, temperature may be set between 180°C to 220°C and proximity bake may be applied.

Strip

AZ 300T and 400T strippers are recommended.

Solvent Safety

BARLi II coatings are formulated with EL/PGME.

Storage

Storing in refrigeration is recommended.

Shelf Life

Shelf life in room temperature is 12 months.



AZ BARLi II Thickness Measurement

The Cauchy coefficients for AZ BARLi II coating are:

A = 1.6097

B = 0.0083014

C = 0.006187

(measured by J. A. Woollam V.A.S.E.® Spectroscopic Ellipsometer)

They fit the following equation:

$$n = A + B/\Sigma^2 + C/\Sigma^4$$

where B in μm^2 , C in μm^4 . If using nm, then multiply B by 10^6 , C by 10^{12} ; If using Å, then multiply B by 10^8 , C by 10^{16} .



Summary

- AZ BARLi II coating material has near-optimum values of refractive indices for i-line lithography.
- AZ BARLi II coating material is formulated in photoresist compatible solvents.
- AZ BARLi II coating material performs comparable to AZ BARLi coating.
- AZ BARLi II coating material is composed of polymer-bound dyes, no sublimation of monomeric dyes and other materials during soft baking.